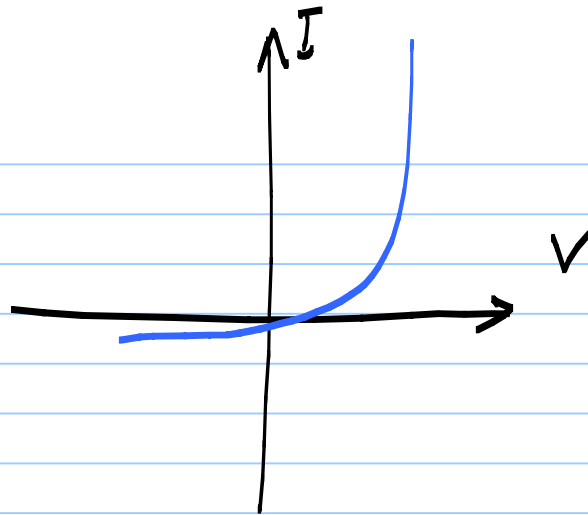
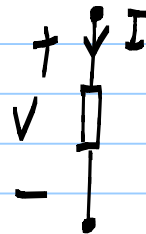
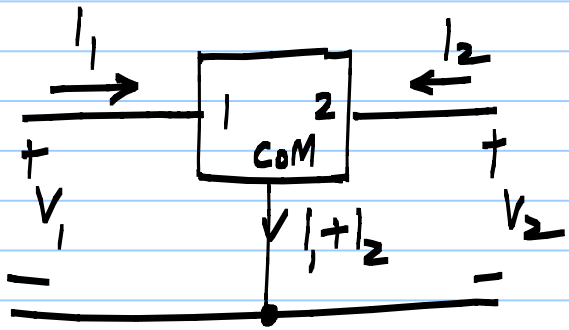


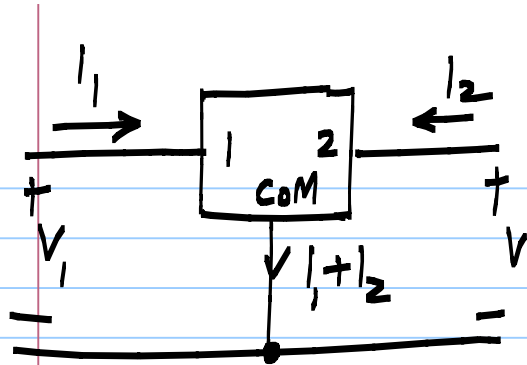
Two port nonlinear elements



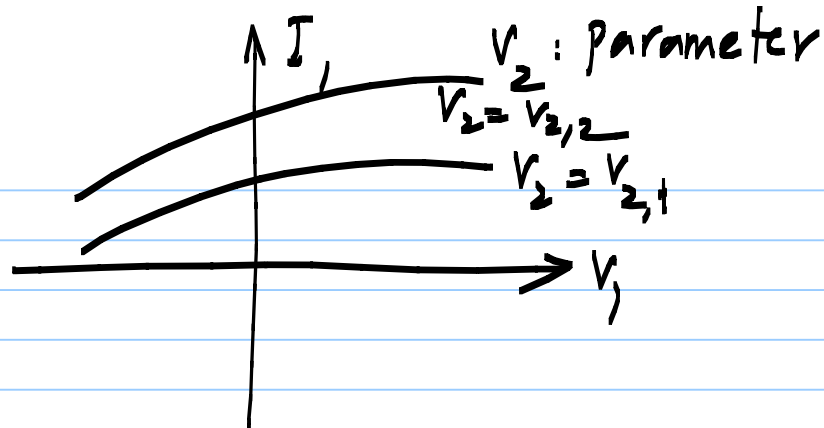
$$\left. \begin{aligned} I_1 &= f_1(V_1, V_2) \\ I_2 &= f_2(V_1, V_2) \end{aligned} \right\}$$

$$\underline{I = f(V)}$$

Representation of a
two port nonlinear element



$$\left. \begin{aligned} I_1 &= f_1(V_1, V_2) \\ I_2 &= f_2(V_1, V_2) \end{aligned} \right\}$$

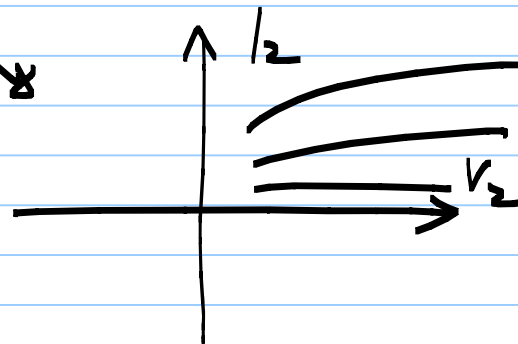
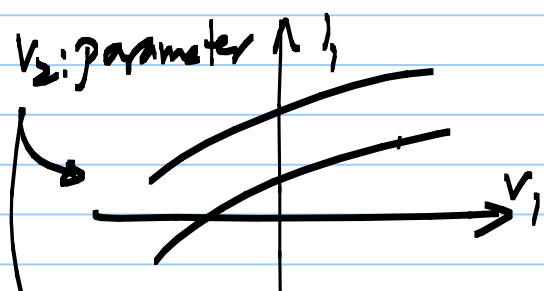


plot I_1 vs. V_1 keeping V_2 constant

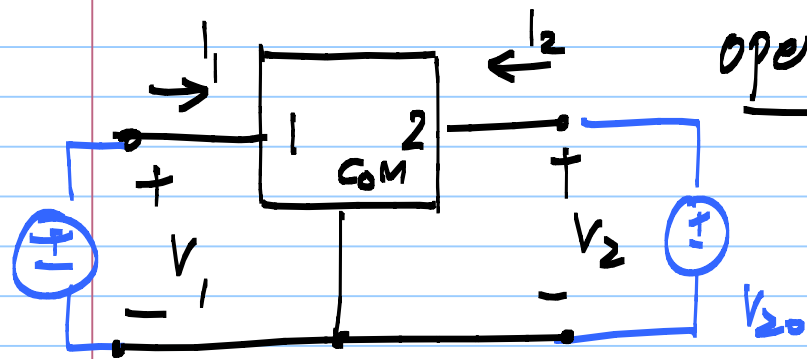
Vary V_2 & repeat the plot

Graphical representation of a two port nonlinearity:

4 plots:



Small signal equivalent of a two port nonlinearity



operating point: $V_{10}, V_{20} \Rightarrow I_{10}, I_{20}$

$$I_{10} = f_1(V_{10}, V_{20})$$

$$I_{20} = f_2(V_{10}, V_{20})$$

$$I_1 = f_1(V_1, V_2)$$

$$I_2 = f_2(V_1, V_2)$$

op. point + increments: $V_{10} + \Delta V_1, V_{20} + \Delta V_2$

$$I_{10} + \Delta I_1, I_{20} + \Delta I_2$$

$$I_{10} = f_1(V_{10}, V_{20}) \quad \text{op. point}$$

$$I_{20} = f_2(V_{10}, V_{20})$$

$$I_{10} + \Delta I_1 = f_1(V_{10} + \Delta V_1, V_{20} + \Delta V_2)$$

$$I_{20} + \Delta I_2 = f_2(V_{10} + \Delta V_1, V_{20} + \Delta V_2)$$

Expand in a Taylor series around the op. point

$$= f_1(V_{10}, V_{20}) + \left. \frac{\partial f_1}{\partial V_1} \right|_{\text{op}} \cdot \Delta V_1 + \left. \frac{\partial f_1}{\partial V_2} \right|_{\text{op}} \cdot \Delta V_2$$

op. point
linear (first order) terms

$$+ \left(\right) \Delta V_1^2 + \left(\right) \Delta V_2^2 + \left(\right) \Delta V_1 \Delta V_2$$

higher order terms
neglected ($\Delta V_1, \Delta V_2$ small enough)

Incremental picture of a nonlinear two-port

$$\begin{bmatrix} y_{11} & y_{12} \\ y_{21} & y_{22} \end{bmatrix}$$

Small signal
(incremental)
y-parameters

$$\Delta I_1 = \left. \frac{\partial f_1}{\partial V_1} \right|_{op} \Delta V_1 + \left. \frac{\partial f_1}{\partial V_2} \right|_{op} \Delta V_2$$

Linear two-port

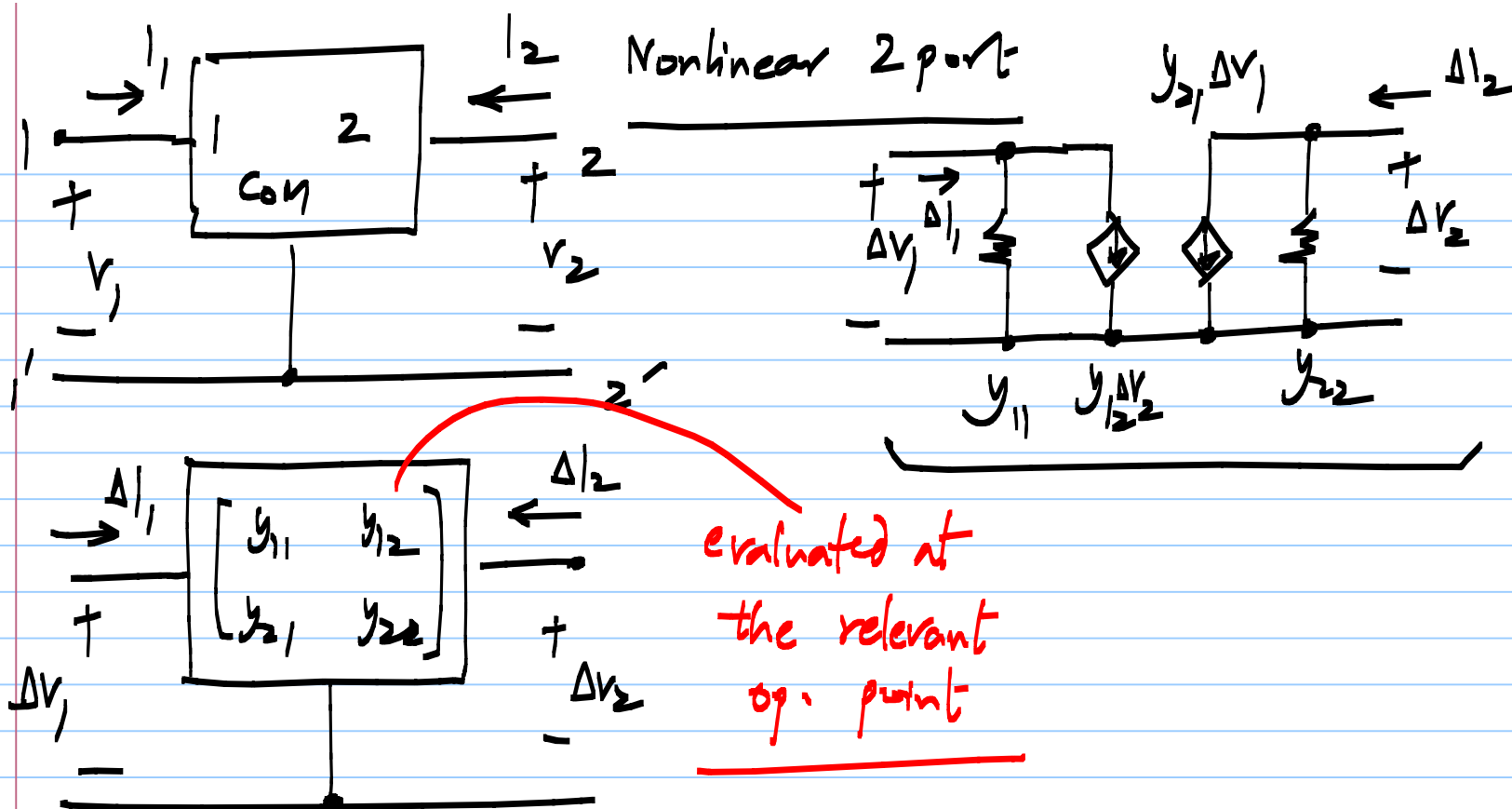
$\Delta V_1, \Delta V_2$

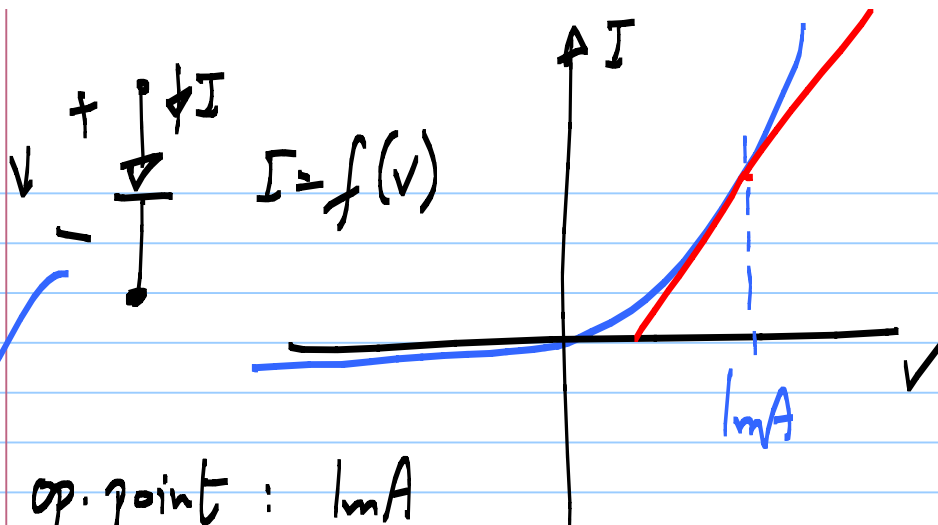
$$\Delta I_2 = \left. \frac{\partial f_2}{\partial V_1} \right|_{op} \Delta V_1 + \left. \frac{\partial f_2}{\partial V_2} \right|_{op} \Delta V_2$$

$\Delta I_1, \Delta I_2$

$$\begin{aligned} \Delta I_1 &= y_{11} \Delta V_1 + y_{12} \Delta V_2 \\ \Delta I_2 &= y_{21} \Delta V_1 + y_{22} \Delta V_2 \end{aligned}$$

effect — cause

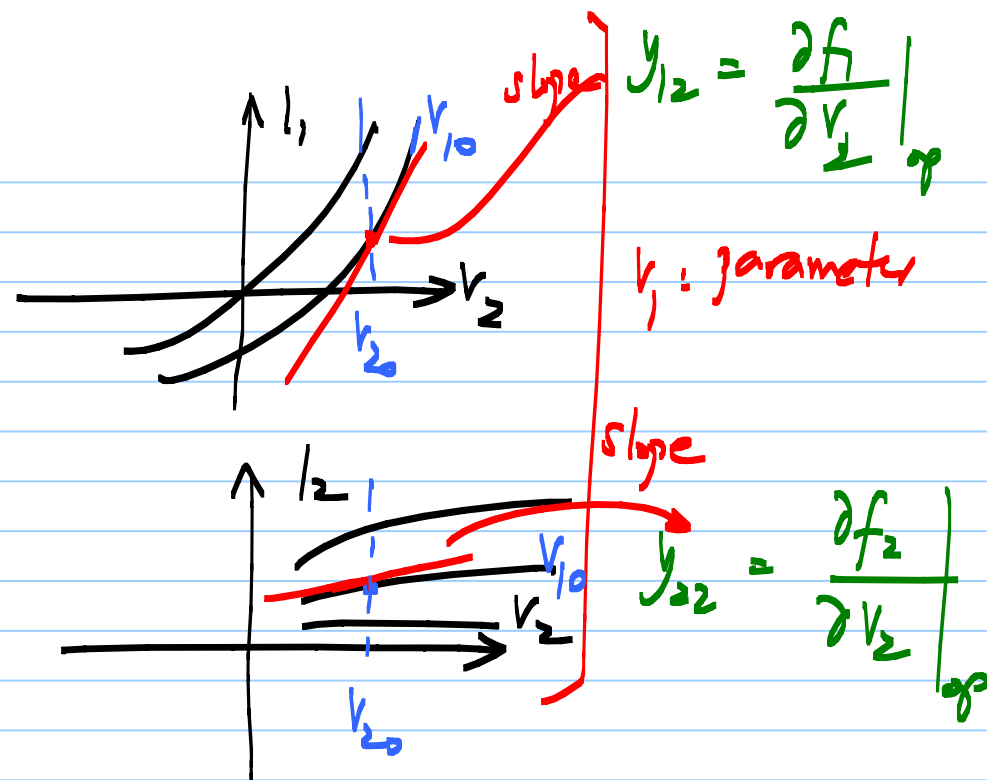
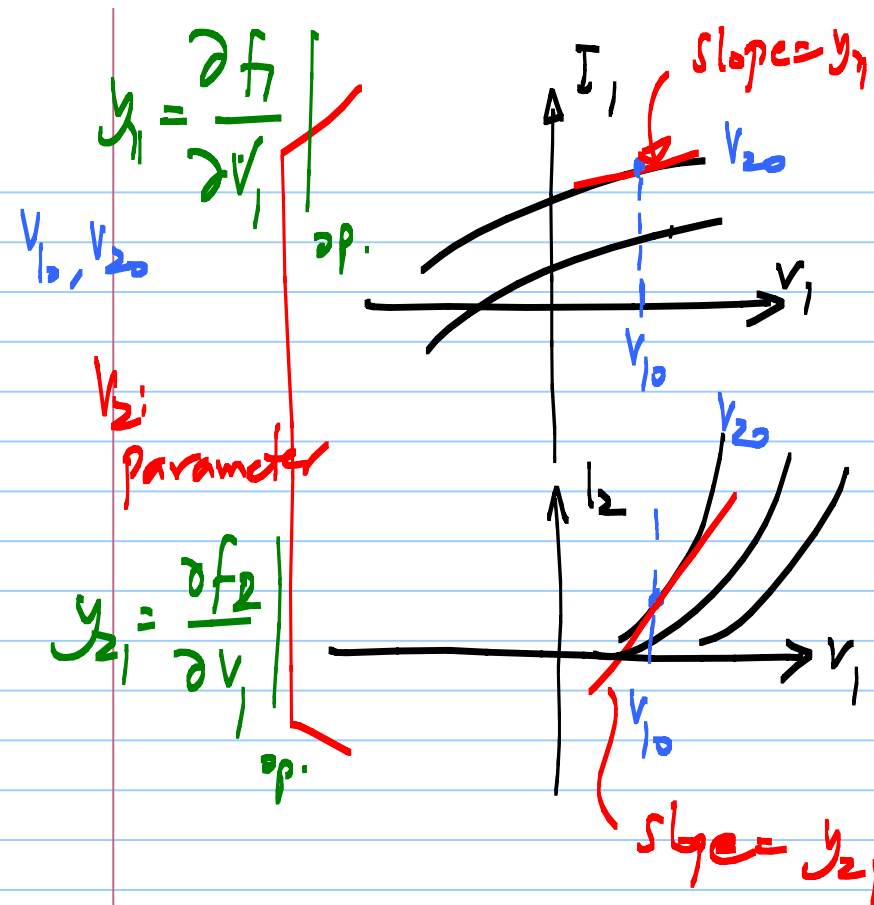




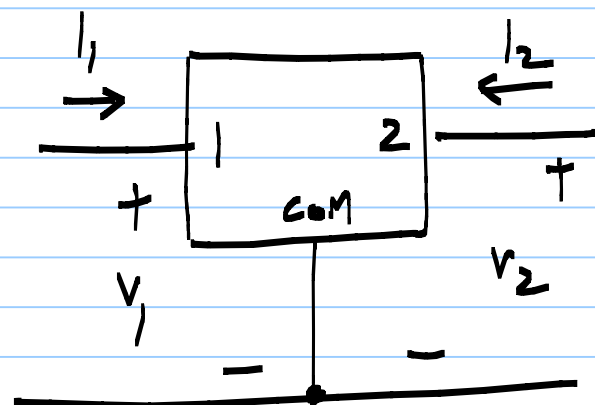
op. point : $I_m A$

s.s. incr. eq.

$$g = f' \big|_{op}$$



Constraints for maximizing the incremental (power) gain of a two-port network



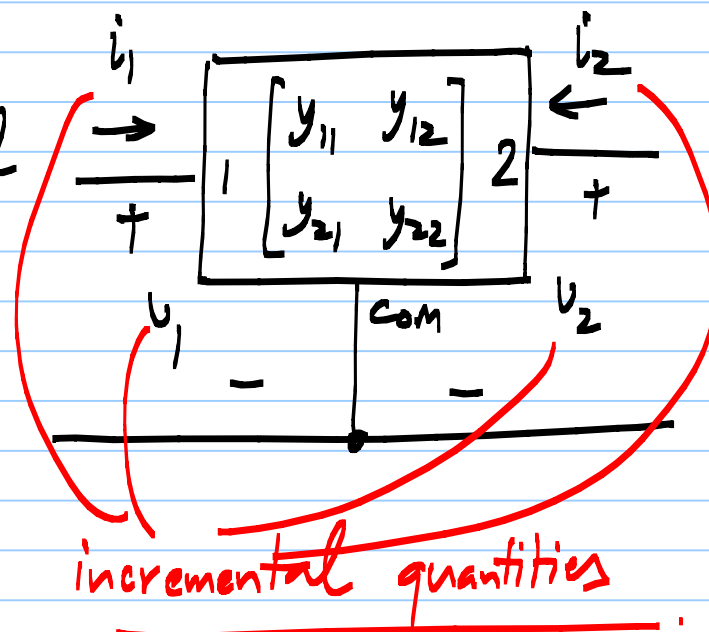
$$i_1 = f_1(v_1, v_2)$$

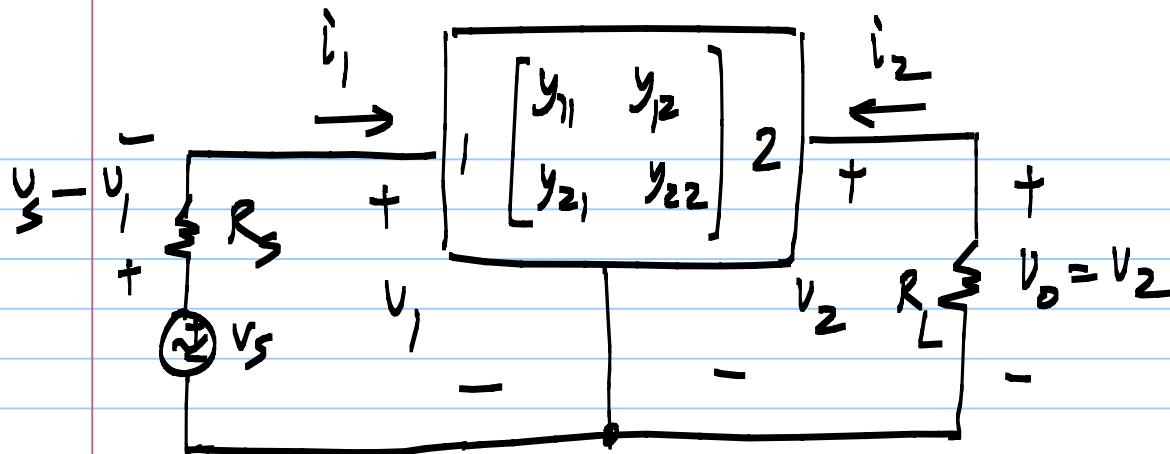
$$i_2 = f_2(v_1, v_2)$$

$$v_{10}, i_{10}$$

$$v_{20}, i_{20}$$

Incremental
eq. dkt





$$\left. \begin{array}{l}
 \text{Signal source} \\
 G_s = 1/R_s \\
 G_L = 1/R_L
 \end{array} \right\} \begin{array}{l}
 i_1 = y_{11} V_1 + y_{12} V_2 \\
 i_2 = y_{21} V_1 + y_{22} V_2 \\
 i_1 = (U_s - V_1) G_s \\
 i_2 = -G_L \cdot V_2
 \end{array}$$

$$i_1 = y_{11} v_1 + y_{12} v_2$$

$$i_2 = y_{21} v_1 + y_{22} v_2$$

$$i_1 = (v_s - v_1) G_s$$

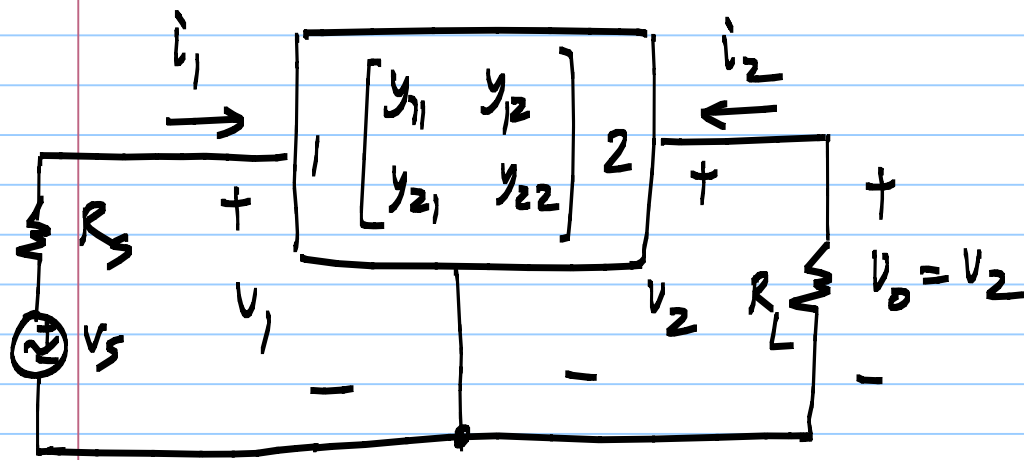
$$i_2 = -G_L \cdot v_2$$

$$\eta = - \frac{(y_{22} + G_L)}{y_{21}} \cdot v_2$$

$$(v_s - v_1) G_s = y_{11} v_1 + y_{12} v_2$$

$$\frac{v_2}{v_s} = \frac{-y_{21} \cdot G_s}{(y_{11} + G_s)(y_{22} + G_L) - y_{12} y_{21}}$$

$$\underbrace{\text{Voltage gain}}_{\text{Power gain}} \rightarrow \frac{v_2^2 / R_L}{[v_s^2 / 4 R_s]}$$



$$\frac{V_2}{V_s} = \frac{-y_{21} \cdot R_s}{(y_{11} + R_s)(y_{22} + R_L) - y_{12}y_{21}}$$

V_s, R_s : signal source

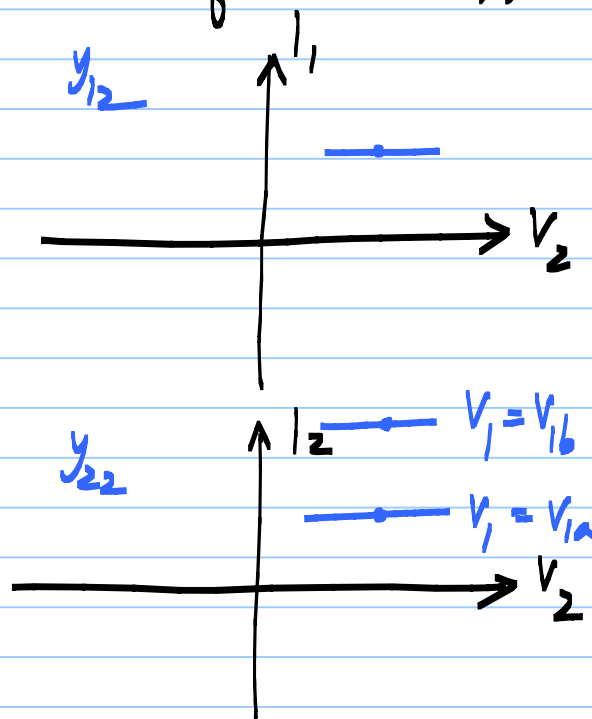
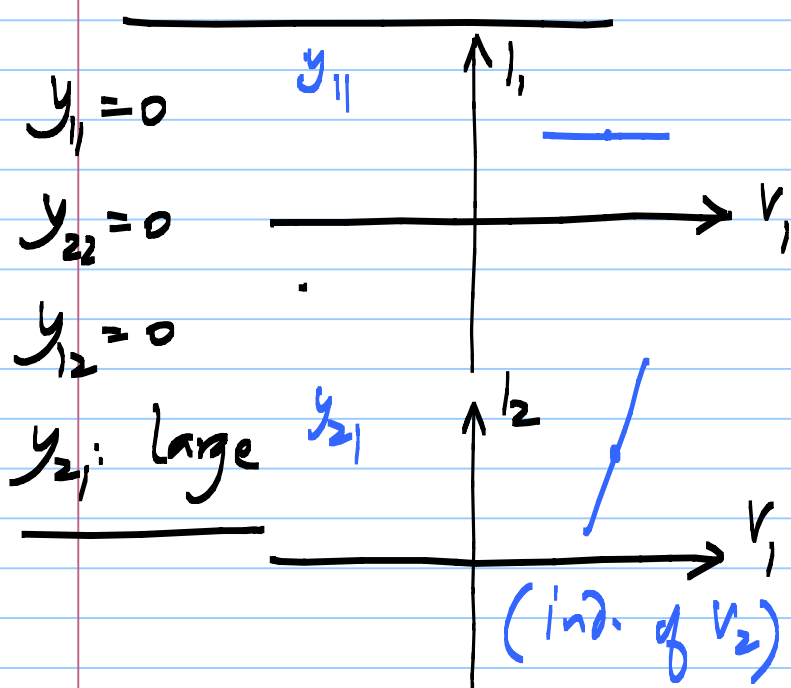
R_L : load

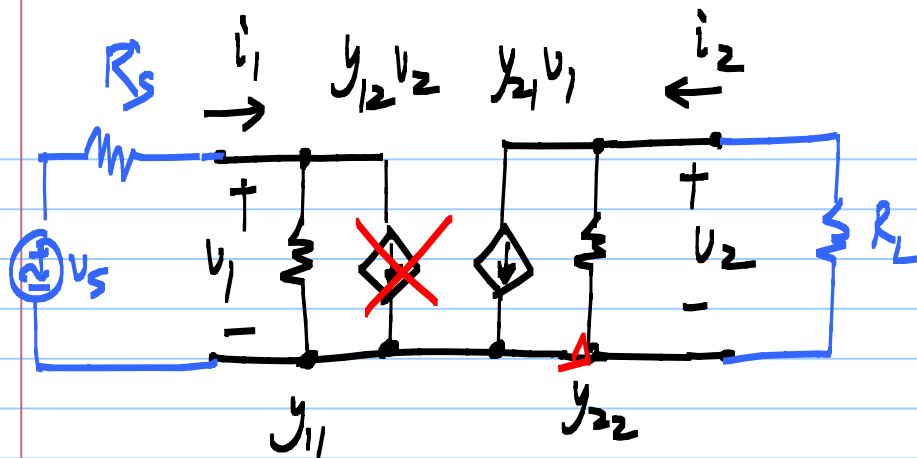
$$y_{11} = 0, y_{22} = 0$$

y_{21} : as large as possible

$y_{12} = 0$ to avoid the possibility of denominator $\rightarrow 0$

Implications on the large signal (total) characteristics of the two-port I_1 : independent of both V_1, V_2





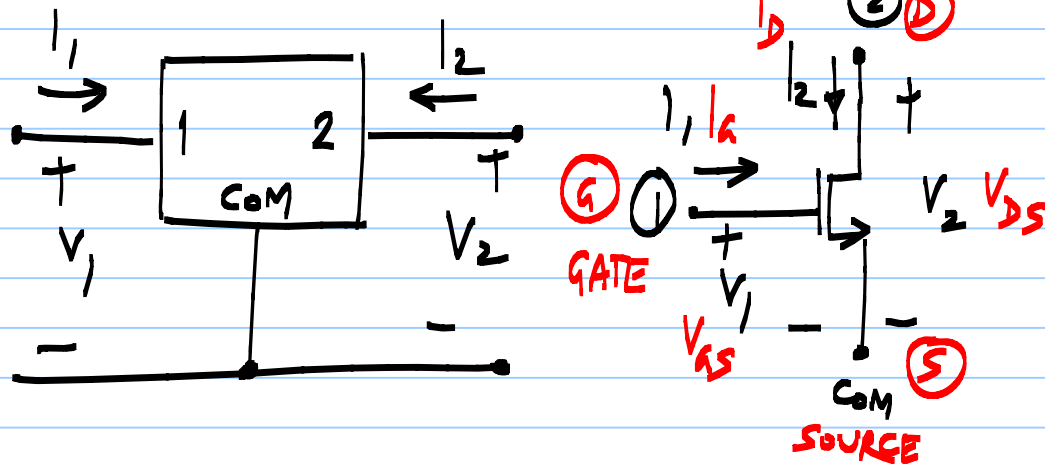
$y_{11} = 0$: open circuited
 \Rightarrow no voltage division

$y_{22} = 0$: open circuited
 \Rightarrow no current division (between y_{22} & R_L)

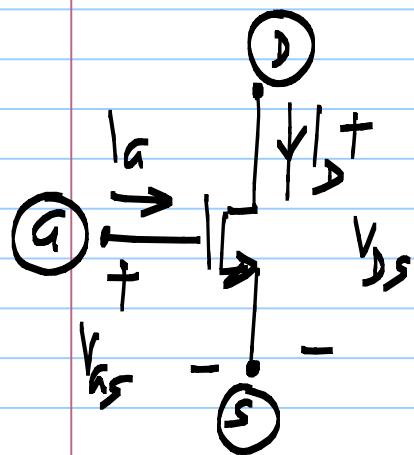
$y_{12} = 0$ (unconditional stability)
 avoid gain $\rightarrow \infty$

MOS transistor

(Metal-oxide-semiconductor)



MOS transistor characteristics :

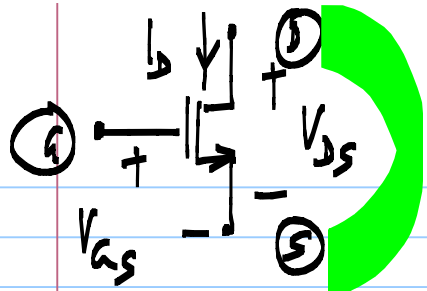


I_d must be constant (independent of both V_{gs} & V_{ds})
 @ some op. point
 $I_d = 0$ independent of V_{gs} & V_{ds}
 (V_1) (V_2)

$$I_d = \frac{\mu_n C_{ox}}{2} \cdot \frac{W}{L} \cdot (V_{gs} - V_T)^2$$

at some op. point

y_{21} : large, ✓

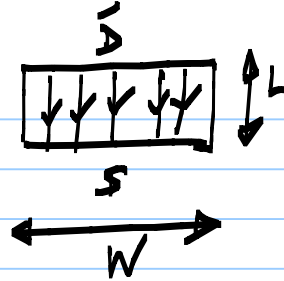


V_T : Threshold voltage

μ_n : Mobility of electrons

C_{ox} : oxide capacitance/unit area

W : width L : length



$V_{gs}, V_{ds} > 0 ; V_T > 0$

$I_D = 0$

cut off

$V_{gs} \leq V_T$

$V_{gs} > V_T$

$V_{ds} \leq V_{gs} - V_T$

triode/
linear
region

$$\mu_n C_{ox} \cdot \frac{W}{L} \left[(V_{gs} - V_T) \cdot V_{ds} - \frac{V_{ds}^2}{2} \right]$$

$$\frac{\mu_n C_{ox}}{2} \cdot \frac{W}{L} (V_{gs} - V_T)^2$$

$V_{gs} > V_T$

$V_{ds} > V_{gs} - V_T$

$$\mu_n C_{ox} \frac{W}{L} = K_n$$

current factor

saturation region

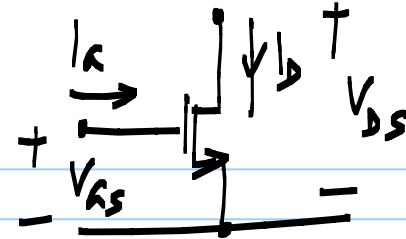
$$I_D = 0$$

$$V_{GS} \leq V_T$$

$$\mu_n C_{ox} \cdot \frac{W}{L} \left[(V_{GS} - V_T) \cdot V_{DS} - \frac{V_{DS}^2}{2} \right]$$

$$V_{GS} > V_T$$

$$V_{DS} \leq V_{GS} - V_T$$

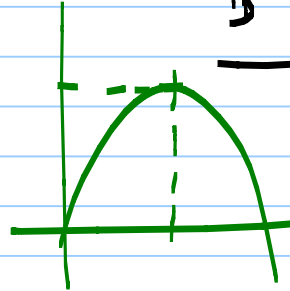


$$I_D \text{ vs. } V_{GS} \quad \& \quad I_D \text{ vs. } V_{DS}$$

$$\frac{\mu_n C_{ox}}{2} \cdot \frac{W}{L} (V_{GS} - V_T)^2$$

$$V_{GS} > V_T$$

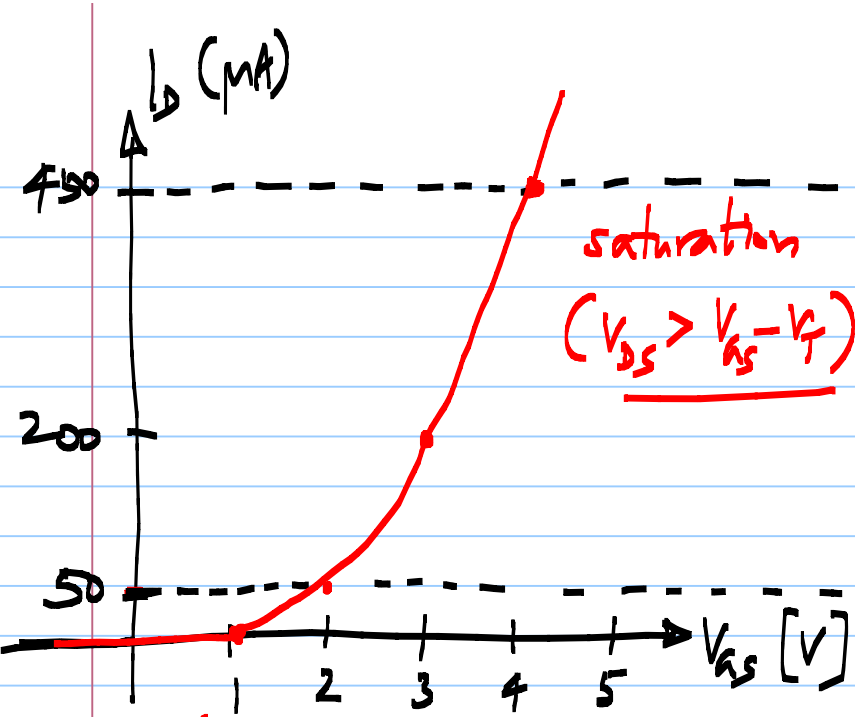
$$V_{DS} > V_{GS} - V_T$$



$$\mu_n C_{ox} = 100 \mu A / V^2$$

$$W/L = 1$$

$$K_n = \mu_n C_{ox} \cdot \frac{W}{L} = \underline{100 \mu A / V^2} ; V_T = 1V$$

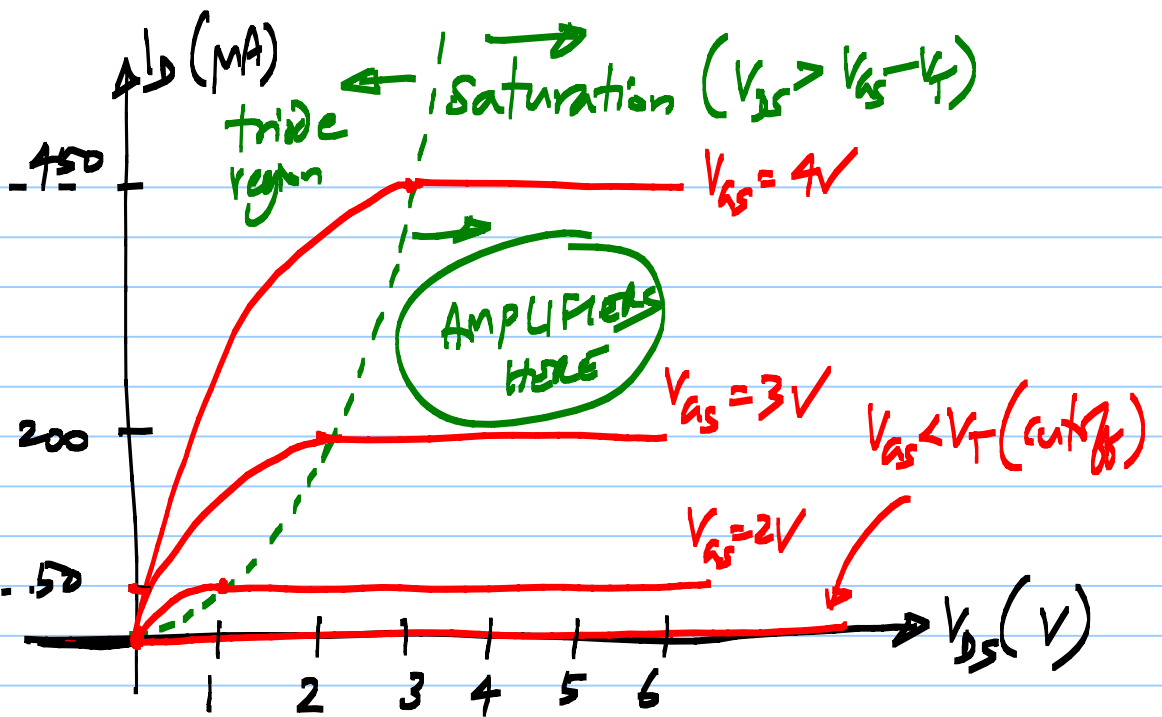


saturation
 $(V_{DS} > V_{GS} - V_T)$

(4)

$$I_D = \frac{\mu_n C_{ox}}{2} \frac{W}{L} (V_{GS} - V_T)^2$$

$V_{DS} > V_{GS} - V_T$
 saturation region



saturation ($V_{DS} > V_{GS} - V_T$)
 triode region


AMPLIFIERS
 HERE

$V_{GS} < V_T$ (cut off)

Small signal model of the MOS transistor

$$I_D = 0 \quad V_{GS} \leq V_T$$

$$\mu_n C_{ox} \cdot \frac{W}{L} \left[(V_{GS} - V_T) \cdot V_{DS} - \frac{V_{DS}^2}{2} \right] \quad \begin{array}{l} V_{GS} > V_T \\ V_{DS} \leq V_{GS} - V_T \end{array}$$

$$\frac{\mu_n C_{ox}}{2} \cdot \frac{W}{L} (V_{GS} - V_T)^2 \quad \begin{array}{l} V_{GS} > V_T \\ V_{DS} > V_{GS} - V_T \end{array}$$


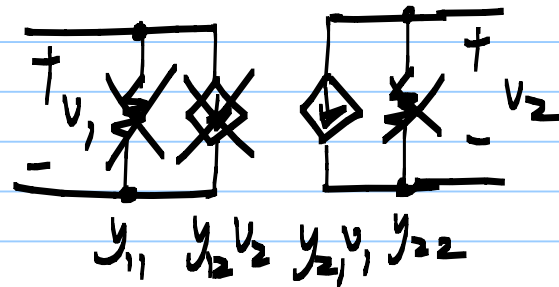
Small signal incremental model in saturation region

$$\mu_n C_{ox} \frac{W}{L} = 100 \mu A/V^2$$

$$V_T = 1V$$

$$\frac{\mu_n C_{ox}}{2} \frac{W}{L} (V_{GS} - V_T)^2$$

$V_{GS} > V_T$
 $V_{DS} > V_{GS} - V_T$



$$y_{21} = \frac{\partial I_D}{\partial V_{GS}} = \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_T) = g_m$$

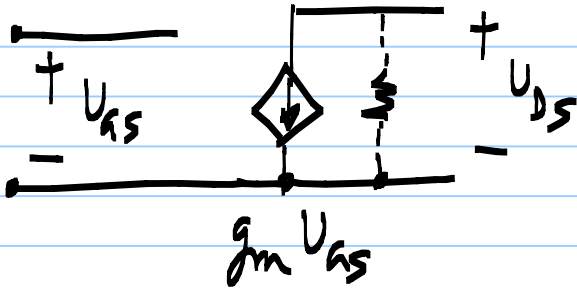
g_m : transconductance

For $V_{GS} = 2V$,
 $g_m = 100 \mu S$

$$y_{22} = \frac{\partial I_D}{\partial V_{DS}} = 0 = g_{ds} \text{ (drain to source conductance)}$$

s.s incremental model of the MOS transistor

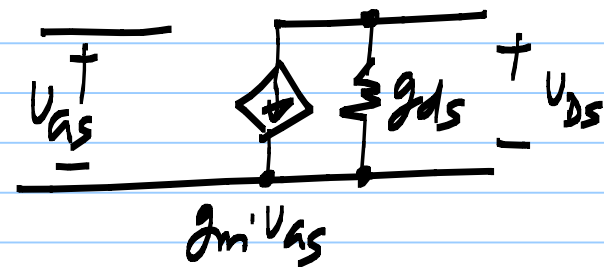
(saturation) $g_{ds} = 0$



$$g_m = \mu_n C_{ox} \frac{W}{L} (V_{gs} - V_T)$$

small signal incremental model in triode (linear) region

$$I_D = \mu_n C_{ox} \frac{W}{L} \left((V_{GS} - V_T) V_{DS} - \frac{V_{DS}^2}{2} \right)$$



$$g_m = \frac{\partial I_D}{\partial V_{GS}} = \mu_n C_{ox} \frac{W}{L} \cdot V_{DS}$$

$$g_{DS} = \frac{\partial I_D}{\partial V_{DS}} = \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_T - V_{DS})$$

Saturation region

Triode (linear) region

$$V_{DS} < (V_{GS} - V_T)$$

$$g_m : \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_T)$$

$$\mu_n C_{ox} \frac{W}{L} \cdot V_{DS}$$

$$g_m(\text{triode}) < g_m(\text{sat.})$$

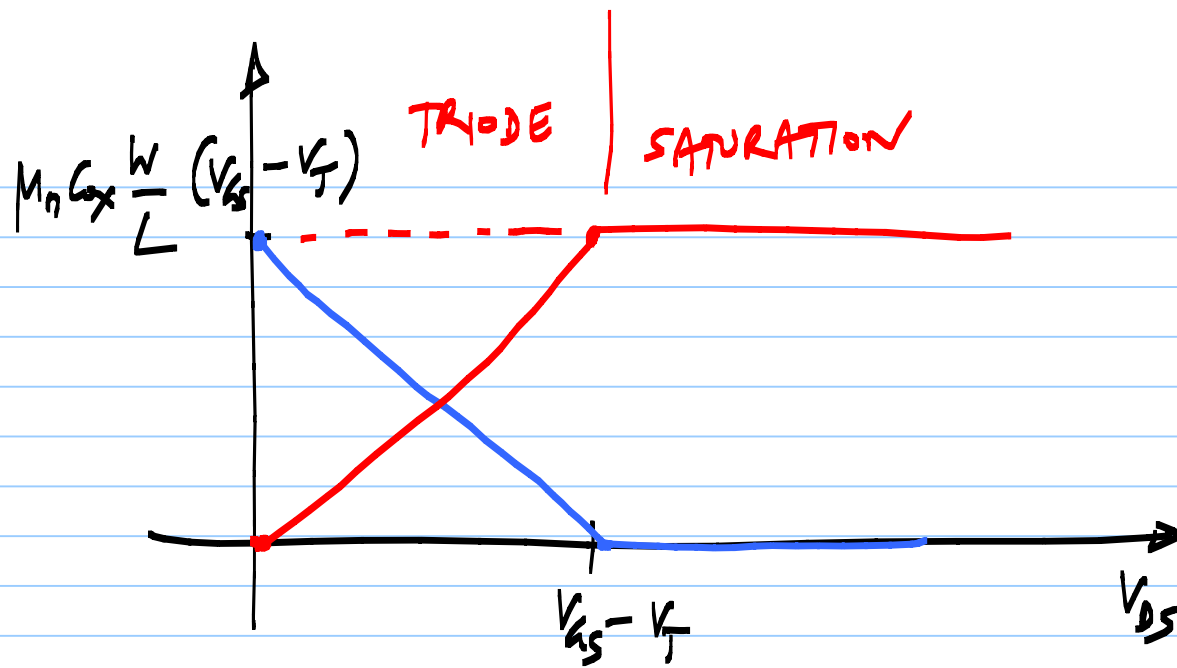
$$g_{DS} : 0$$

$$\mu_n C_{ox} \frac{W}{L} (V_{GS} - V_T - V_{DS}) \quad 0 < V_{DS} < V_{GS} - V_T$$

$$V_{DS} : 0 \text{ to } V_{GS} - V_T$$

$$g_{DS} : \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_T) \text{ to zero}$$

$$g_m : 0 \text{ to } \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_T)$$



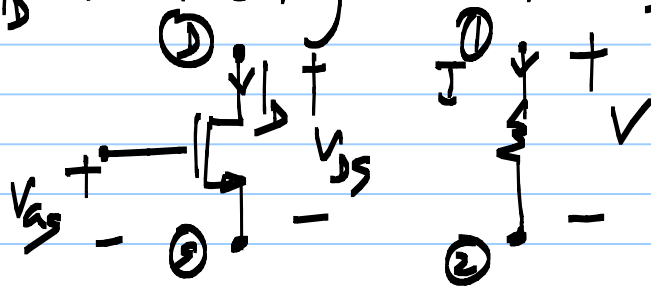
$$I_D = \mu_n C_{ox} \frac{W}{L} \left((V_{GS} - V_T) V_{DS} - \frac{V_{DS}^2}{2} \right) \begin{cases} V_{GS} > V_T \\ V_{DS} < V_{GS} - V_T \end{cases}$$

$$V_{DS} \ll V_{GS} - V_T \quad \left(V_{GS} - V_T - \frac{V_{DS}}{2} \right) V_{DS}$$

$$I_D \approx \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_T) V_{DS}$$

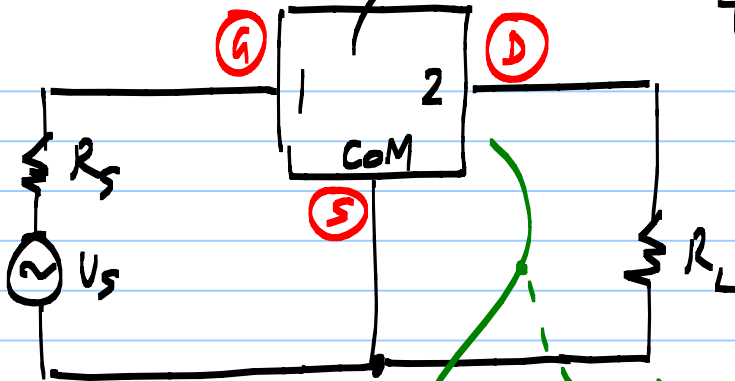
I_D : linearly with V_{DS}

(linear region)



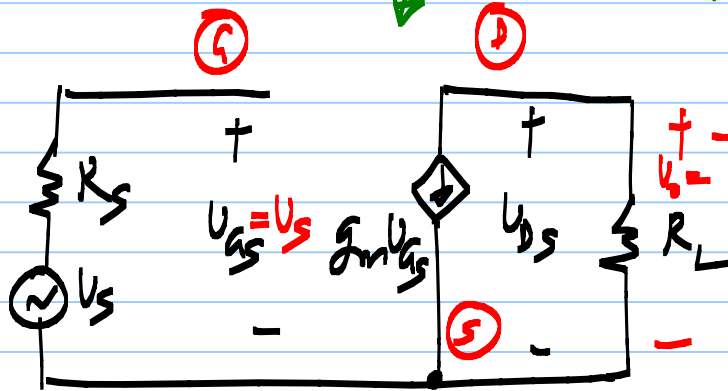
MOS in triode region: Voltage controlled resistor

Incremental eq. of
the NL two port



$$U_o = \underbrace{(-g_m R_L)}_{\text{gain}} \cdot U_s$$

incremental eq. of MOS
in saturation region



$$U_o = g_m R_L U_s$$

Incremental eq.
of the amplifier